

Application Data Sheet**Application Information**

Application Type::	Regular
Subject Matter::	Utility
CD-ROM or CD-R:	None
Title::	MALEIC ACID AND ETHYLENE UREA CONTAINING FORMULATION FOR REMOVING RESIDUE FROM SEMICONDUCTOR SUBSTRATE AND METHOD FOR CLEANING WAFER
Attorney Docket Number::	117641
Suggested Drawing Figure::	
Total Drawing Sheets::	
Small Entity::	No

Applicant Information

Applicant Authority type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Tomoe
Family Name::	MIYAZAWA
City of Residence::	Funabashi-shi
Country of Residence::	JAPAN

Applicant Authority type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Yoichiro
Family Name::	FUJITA
City of Residence::	Funabashi-shi
Country of Residence::	JAPAN

Applicant Authority type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Ichiro
Family Name::	KOBAYASHI
City of Residence::	Funabashi-shi
Country of Residence::	JAPAN

Correspondence Information

Correspondence Customer Number:: 25944

Assignee Information	
Assignee Name::	NISSAN CHEMICAL INDUSTRIES, LTD.
Street of mailing address::	7-1, Kandanishiki-cho 3-chome, Chiyoda-ku,
City of mailing address::	Tokyo
Country of mailing address::	JAPAN
Postal or Zip Code of mailing address::	101-0054